

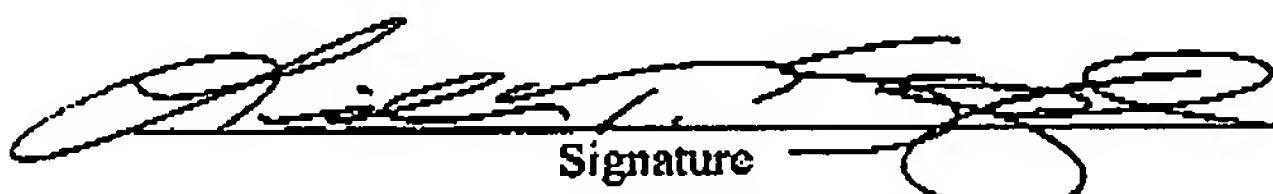
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

RECEIVED
CENTRAL FAX CENTER**Serial No.:** 10/707,388**Conf. No.:** 1387**OCT 14 2005****Filing Date:** 12/10/2003**Art Unit:** 2891**Applicant:** Divakaruni et al.**Examiner:** Fulk, Steven J.**Title:** SILICIDE RESISTOR IN BEOL
LAYER OF SEMICONDUCTOR
DEVICE AND METHOD**Docket No.:** FJS920030274US1
(IBMF-0032)**COMMISSIONER FOR PATENTS****DESTINATION FACSIMILE NUMBER:** 571-273-8300Transmitted herewith is: **Request for Reconsideration in 8 pages**

in the above identified application.

CERTIFICATION OF FACSIMILE TRANSMISSION

I hereby certify that this correspondence is being facsimile transmitted to the United States Patent and Trademark Office on the date shown below.

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October 14, 2005

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RECEIVED**CENTRAL FAX CENTER****OCT 14 2005****IN THE UNITED STATES PATENT AND TRADEMARK OFFICE****In Re Application of: Divakaruni et al.****Conf. No.: 1387****Serial No.: 10/707,388****Art Unit: 2891****Filed: 12/10/2003****Dkt. #: FIS920030274US1 (IBMF-0032)****Title: SILICIDE RESISTOR IN BEOL
LAYER OF SEMICONDUCTOR
DEVICE AND METHOD****Examiner: Fulk, Steven J.**

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REQUEST FOR RECONSIDERATION**Sir:****I. INTRODUCTORY COMMENTS:**

In response to the Office Action of July 28, 2005, please reconsider the above-referenced patent application in view of the following remarks: